Effect of Non-Thermal Argon Plasma on Bond Strength of a Self-Etch Adhesive System to NaOCl-Treated Dentin

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Studies have been showing a decrease of bond strength in dentin treated with sodium hypochlorite (NaOCl). The aim of this study was to evaluate the effect of non-thermal argon plasma on the bond strength of a self-etch adhesive system to dentin exposed to NaOCl. Thirty-two flat dentin surfaces of bovine incisors were immersed in 2.5% NaOCl for 30 min to simulate the irrigation step during endodontic treatment. The specimens were divided into four groups (n=8), according to the surface treatment: Control (without plasma treatment), AR15 (argon plasma for 15 s), AR30 (argon plasma for 30 s) and AR45 (argon plasma for 45 s). For microtensile bond strength test, 5 specimens were used per group. In each group, the specimens were hybridized with a self-etch adhesive system (Clearfil SE Bond) and resin composite buildups were constructed. After 48 h of water storage, specimens were sectioned into sticks (5 per tooth, 25 per group) and subjected to microtensile bond strength test (μTBS) until failure, evaluating failure mode. Three specimens per group were analyzed under FTIR spectroscopy to verify the chemical modifications produced in dentin. μTBS data were analyzed using ANOVA and Tamhane tests (p<0.05). AR30 showed the highest μTBS (20.86±9.0). AR15 (13.81±6.4) and AR45 (11.51±6.8) were statistically similar to control (13.67±8.1). FTIR spectroscopy showed that argon plasma treatment produced chemical modifications in dentin. In conclusion, non-thermal argon plasma treatment for 30 s produced chemical changes in dentin and improved the μTBS of Clearfil SE Bond to NaOCl-treated dentin.

Introduction

The main goal of endodontic treatment is the complete apical and coronal seal of root canal system to prevent percolation and bacterial leakage (1). The infiltration of oral microorganisms through the filling of the root canals is favored by the absence of a correct coronal sealing, harming the prognosis of these treatments (2,3).

The mechanic preparation is able to remove a great number of bacteria in the main canal, but there are areas that are not removed by the instruments, due to the complex anatomy of the root canal systems (4,5). Many irrigating solutions have been used to reach those areas, and remove debris and necrotic tissue. Nowadays, the sodium hypochlorite (NaOCl) is the most used auxiliary chemical substance among endodontists worldwide (6). This fact is due to this solution being the only with the capacity to tissue dissolution and broad-spectrum antimicrobial activity (7). However, during its action in the root canal, there is formation of free oxygen. This nascent oxygen causes a strong inhibition in the polymerization next to the interface of the adhesive materials (8). Because of this inhibition in polymerization, studies have been showing an increase of coronal micro-infiltration and a decrease in the levels of bond resistance in endodontically treated teeth (9-11). Solutions like ascorbic acid have been proposed to reduce this effect, but the required contact time for inhibition is too long and clinically unpractical (12).

The use of plasma technology has expanded its actuation area to obtain increase of surface wettability and, consequently, the bond resistance between interfaces of different compositions. This technology consists in chemical modification of a surface by a gas or a combination of gases. In dentistry, it was proposed aiming the increase in coronal adhesion levels (13), adhesion between fiber posts and resin cements (14) and in the disinfection of root canals (15). Different gases were used, including argon, EDA, helium and oxygen (13-16).

The objective of the present study was to evaluate the effect of non-thermal argon plasma on bond strength of a self-etch adhesive system to NaOCl-exposed coronal dentin.

Material and Methods

Specimen Preparation

The crowns of 32 bovine incisors were separated from the roots and sectioned parallel to their long axis and through the pulp chamber using a diamond disc (KG Sorensen, Cotia, SP, Brazil). The dentin from the buccal halves of the crowns were wet ground with silicon carbide paper 200, 500 and #600 to produce flat dentin surfaces.
and standardize the thickness of the smear layer (17).

**Surface Treatments**

The dentin surfaces were immersed in 2.5% NaOCl (Formulativa, Rio de Janeiro, RJ, Brazil) for 30 min, in order to simulate the irrigation step during endodontic treatment, ultrasonically cleaned for 5 min and divided into four groups (n=8) according to the surface treatments (Table 1).

**Plasma Treatment**

A glass reactor was used for non-thermal plasma treatment. This reactor consists of a 5 cm diameter and 30 cm long tube, evacuated by a mechanical pump, down to pressures lower than 2 Pa. Gas was allowed to fill the reactor up to a pressure of 10 Pa. Non-thermal plasma was generated within the glass cylinder under vacuum by the action of an induced magnetic field from the current passing through an electrical coil surrounding the cylinder. Surfaces were treated using argon gas (White Martins, Rio de Janeiro, RJ, Brazil) at 60 W for 15, 30 or 45 s. At the end of the process, radio frequency was turned off before the samples were exposed to air.

**Microtensile Test**

For microtensile test, five specimens were used per group (n=5). The sample size calculation of this research was based on previous laboratory studies (18,19). After the treatments described in Table 1, specimens were hybridized with a self-etch adhesive system (Clearfil SE Bond, Kuraray, Japan) applied according to the manufacturer’s instructions and light cured using a LED curing unit (Radii-Cal, SDI, Victoria, Australia). Using a silicon matrix, resin composite buildups (Z350XT, 3M ESPE, St. Paul, MN, USA) were constructed on the dentin surfaces in 2 mm increments, each light cured for 20 s with an irradiance of 1200 mW/cm² (Radii-Cal, SDI). After 48 h of storage in distilled water, the bonded specimens were serially sectioned in the “x” and “y” directions across the bonded interfaces (IsoMet 1000, Buehler, Lake Bluff, IL, USA) to obtain sticks with a cross-sectional area of approximately 1.0 mm². Five sticks were evaluated per specimens, totaling twenty-five sticks per group (18,19).

The sticks had their cross-sectional area at adhesive interfaces measured with a digital caliper (MPI/E-101, Mytutoyo, Tokyo, Japan) and individually fixed to a microtensile device (ODMT03d, Odeme Biotechnology, Joaçaba, SC, Brazil) with cyanoacrylate glue (Locitite Superbonder Ge®, Henkel Adesivos LTDA, Itapevi, SP, Brazil) and loaded under tension using a universal testing machine (EMIC DL 2000, São José dos Pinhais, PR, Brazil) at a crosshead speed of 1.0 mm/min until failure. The μTBS (MPa) was obtained dividing the load at failure (N) by the cross-sectional area (mm²).

For statistical analysis, normal distribution of the μTBS data was checked using the Kolmogorov-Smirnov test. Difference between groups was analyzed using the ANOVA and Tamhane tests (p<0.05).

Failure modes were evaluated at 40x magnification (SZ61TR Olympus, Tokyo, Japan) and classified as adhesive (at resin/dentine interface); cohesive (in resin or in dentin) and mixed (combined fracture) (20). Representative specimens from each group were evaluated by scanning electron microscopy at 1500×, 2500× and 5000× magnifications (Phenom ProX, Phenom-World, Eindhoven, Holland).

**FTIR Analysis**

In order to analyze the effect of the treatments in dentin, the three remaining dentin surfaces of each group were evaluated by Fourier transform infrared spectroscopy (FTIR). Infrared analysis was performed on a Nicolet 6700 spectrometer (Thermo Scientific, Waltham, MA, USA) in ATR mode and all spectra were acquired in absorbance mode in the 650-4000 cm⁻¹ range. FTIR analyses were performed before and after adhesive application. In order to compare the degree of conversion of the adhesive in different groups, the relation (R) between the absorbance peaks intensity of aliphatic C=C (Al), located at 1635 cm⁻¹, and aromatic C=C (Ar), located at 1606 cm⁻¹, was calculated in each spectrum using the equation: (R)= Al/Ar (21), with the aromatic absorption function as an internal standard (22).

**Results**

**Microtensile Test**

Means and standard deviation of bond strength (in MPa) for the Control, AR15, AR30 and AR45 groups were, respectively, 13.67±8.1, 3.81±6.4, 20.86±9.0 and 1.51±6.8. Control, plasma 15 s and 45 s showed the lowest values, without statistically significant difference between them (p>0.05). The plasma treatment for 30 s increased the bond strength, showing the highest value and differing significantly form the other groups (p<0.05).

**Failure Mode**

The distribution of the failure modes observed in optic
microscopy is in Figure 1. Compared with the other groups, AR30 had significantly less adhesive fractures, showing higher values of cohesive or mixed patterns. Control, AR15 and AR45 showed high numbers of adhesive fractures and the first had no cohesive failures. Figure 2 shows representative images of different fracture patterns.

**FTIR Analysis**

FTIR spectra from different groups without adhesive system application are in Figure 3A. Spectra were normalized using the phosphate peak at 1025 cm$^{-1}$. Modifications observed between the 1400 cm$^{-1}$ and 1700 cm$^{-1}$ peaks demonstrate chemical changes in organic structure of dentin, where the peak close to 1600 cm$^{-1}$ corresponds to the stretching vibration of the C=O bond (νC=O) from amide I. The 1445 cm$^{-1}$ peak corresponds to the carbonate band (23). The band between 1500 and 1600 cm$^{-1}$ corresponds to the stretching vibration of C-N bond (νC-N) from amide II. The AR30 band close to 3.000 cm$^{-1}$ represents the stretching vibration of the C-H bond (νC-H) and at 3.500 cm$^{-1}$ to O-H (νO-H).

Figure 3B shows the FTIR spectra from different groups after adhesive system application. Spectra were normalized using the 1720 cm$^{-1}$ peak that corresponds to the stretching vibration of C=O bond (νC=O). The 1155 cm$^{-1}$ peak corresponds to C-OH bond (νC-OH). The 1635 cm$^{-1}$ and 1606 cm$^{-1}$ peaks correspond to aliphatic and aromatic C=C bonds, respectively, and the relation between its absorbance peak intensity (R) is in Table 2.

**Discussion**

Self-etch adhesives, especially those containing 10-MDP functional monomer, are a reliable method of bonding to dentin. The use of self-etch adhesives allows for a less sensitive technique, because it involves fewer steps. Different from systems that use phosphoric acid etching, in this system the collagen fibers remain protected by the hydroxyapatite and do not undergo hydrolase, which is advantageous for bonding durability (24).

Deproteinizing effect of sodium-hypochlorite (NaOCl) pretreatment on smear layer-covered dentine for a short time (15 s) had no negative effect on bond strength of self-etch adhesive to dentin. However, from 30 s or more, it reduced the bond strength values compared with non-treated dentin (25). This occurs due the residual oxidizing effect in NaOCl-treated dentine, causing premature chain termination and incomplete resin polymerization of adhesive materials (8).

Non-thermal plasma treatment usually acts modifying or etching surfaces. The first acts generally creating new chemical structures. Etching is the removal of chemical structures from the surface. Previous studies observed that

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**Figure 1.** Failure patterns (%) from each group.

**Figure 2.** Representative SEM images of different failure patterns: adhesive (A), cohesive in resin (B), cohesive in dentin (C) and mixed (D). In adhesive failure, adhesive tags may be seen inside dentin tubules (red arrows).
argon plasma before restoration improved the adhesive properties of dentin (13,14).

In the present study, this treatment was proposed in order to restore the bond strength of the NaOCl-treated dentin. Short terms (15, 30 and 45 s) were evaluated to allow its clinical use. Additionally, it was previously observed that argon plasma treatment for 30 s improved bond strength of adhesive systems to dentin and longer exposure time may decrease bond strength values (13).

When argon plasma treatment was compared with control group, the lowest values of bond strength were obtained from control and argon plasma treatment for 15 and 45 s, as confirmed by the failure patterns. These groups showed higher amount of adhesive fractures. On the other hand, fracture patterns of argon plasma for 30 s confirmed the higher bond strength values, showing less adhesive fractures and more cohesive and/or mixed fractures.

FTIR analysis showed that plasma reduced significantly the OH functionality on the dentin surface. Observing the band between 1400 cm$^{-1}$ and 1700 cm$^{-1}$, NaOCl irrigation reduced the amides grouping of the smear layer. Plasma treatment for 15 s further reduces amide I (peak at 1640 cm$^{-1}$) and treatment by 30 s and 45 s completely removed it. Plasma treatment also reduced amide II (1500–1600 cm$^{-1}$) corresponds to the stretching vibration of C–N bond). Argon plasma for 30 s showed a difference in the aromatic amines (1250–1335 cm$^{-1}$) corresponds to the stretching vibration of C–N bond) and in the carbonyl stretch (around 1760 cm$^{-1}$). The carbonyl groups on the surface are associated

#### Table 2. Ratio between aliphatic and aromatic C=C bonds

<table>
<thead>
<tr>
<th>Group</th>
<th>Al/Ar ratio</th>
</tr>
</thead>
<tbody>
<tr>
<td>Control</td>
<td>1.083214853</td>
</tr>
<tr>
<td>AR15</td>
<td>1.444589764</td>
</tr>
<tr>
<td>AR30</td>
<td>2.188986233</td>
</tr>
<tr>
<td>AR45</td>
<td>1.538590604</td>
</tr>
</tbody>
</table>

Figure 3. FTIR spectra of different groups without adhesive system application (A) and FTIR spectra of different groups after adhesive system application (B).
with organic components of the smear layer and dentin (collagen fibrils). May be it increased hydrogen bonding interactions of the collagen fibrils with the adhesive that was subsequently applied to the dentin surfaces for test specimen preparation, and in this way favored the adhesion process. When argon plasma of 45 s FTIR spectrum is analyzed, it can be observed that, in relation to the phosphate peak, all peaks increased. As the phosphate peak was the one used for normalization of all spectra, this increase of all peaks may be related to a decrease in the phosphate content of the dentin. Thus, the negative results of 45 s may be associated with a prolonged plasma exposure that could start degrading the dentin inorganic structure with the reduction of phosphate species in relation to the carboxylic groups.

After adhesive system application, chemical alterations were also observed in plasma treated groups. Peak of 1155 cm\(^{-1}\) refers to C-OH bonding (vC-OH), where argon 30 s group showed lower formation of C-0H bonds compared with other groups. C-OH bonding results in a shorter polymer chain, which is an indication of a low degree of polymerization. Another indication is that argon plasma of 30 s showed higher values in the relation between the aliphatic C=C bonding (peak at 1635 cm\(^{-1}\)) and aromatic C=C bonding (peak at 1608 cm\(^{-1}\)), indicating a higher degree of conversion of the adhesive in this group. This higher conversion is associated with the increase of the aliphatic C=C bonding since there has been no change in the aromatic C=C bonding. This finding may explain the higher bond strength values obtained in microtensile test in the present study for 30 s.

The findings of the present study indicated that argon plasma treatment for 30 s improved the bond strength of dentin previously exposed to NaOCl. According to other recent studies, the chemical changes and their influence on adhesive properties promoted by plasma treatment have been demonstrated (13,14). From the statistical data, it seems that argon plasma treatment is a promising procedure to improve bonding quality of composite to dentin. Although, further studies should be done to gather more details of argon plasma effect on the organic component of dentin, analyzing the different periods of application and its implication on adhesive properties, establishing a standard protocol for argon plasma treatment.

It may be concluded that non-thermal argon plasma treatment for 30 s improved μTBS of Clearfil SE bond to NaOCl-treated dentin, promoting chemical changes in the dentin structure.

Resumo

Estudos vêm demonstrando uma diminuição na resistência adesiva em dentina tratada com hipoclorito de sódio (NaOCl). O objetivo desse estudo foi avaliar o efeito do plasma de argônio não-térmico na resistência de união de um sistema adesivo autocondicionante à dentina exposta ao NaOCl. Trinta e duas superfícies dentinárias lisas de incisivos bovinos foram imersas em NaOCl a 2,5% por 30 min para simular o passo de irrigação durante o tratamento endodôntico. Os espécimes foram divididos em 4 grupos (n=8), de acordo com o tratamento de superfície: Controle (sem tratamento de plasma), AR15 (plasma de argônio por 15 s), AR30 (plasma de argônio por 30 s) e AR45 (plasma de argônio por 45 s). Para teste de resistência de união por microtração, cinco espécimes foram utilizados por grupo. Em cada grupo, os espécimes foram hibridizados com um sistema adesivo autocondicionante (Clearfil SE Bond, Kuraray) e blocos de resina composta foram construídos. Após 48 h de armazenamento em água, os espécimes foram secionados em palitos (5 por dente – 25 por grupo) e submetidos ao teste de resistência de união por microtração (μTBS) até a fratura, avaliando o padrão de fratura. Três amostras por grupo foram analisadas sob espectroscopia por FTIR para verificar as alterações químicas produzidas pelos tratamentos na dentina. Os dados de microtração foram avaliados estatisticamente utilizando os testes de ANOVA e Tamhane (p<0,05). AR30 apresentou o maior μTBS (20,86±9,0), AR15 (13,81±6,4) e AR45 (11,51±6,8) foram estatisticamente semelhantes ao controle (13,67±8,1). A espectroscopia por FTIR mostrou que o plasma de argônio produz alterações químicas na dentina. Como conclusão, o plasma de argônio não-térmico por 30 s produziu alterações químicas na dentina e melhorou o μTBS do Clearfil SE Bond à dentina tratada com NaOCl.

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